

# Broadband Continuous Wavelength Conversion of 10-Gb/s Data in Silicon Waveguides Spanning S-, C-, and L-Bands

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**Abstract:** We demonstrate broadband continuous wavelength conversion of 10-Gb/s data across 100 nm using four-wave mixing in dispersion-engineered silicon waveguides. Error-free operation and constant 2-dB power penalties are experimentally obtained for all examined probe-idler separations.

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## 1. Introduction

Ever-increasing bandwidth demands in optical communication networks are placing a greater emphasis on all-optical processing systems capable of replacing optically-opaque electrical counterparts that employ power-hungry transceivers. Network-level all-optical parametric systems utilizing wavelength conversion, wavelength multicasting, and temporal demultiplexing empower this new networking domain with enhanced performance, energy efficiency, and long-term scalability. Such enabling devices leveraging four-wave mixing (FWM) for all-optical parametric processing have been demonstrated in highly-nonlinear fiber (HNLF) [1], III-V semiconductors [2], chalcogenides [3], silicon [4], as well as silicon-organic hybrid systems [5].

Recent advances in complementary metal-oxide-semiconductor (CMOS)-compatible silicon photonic devices have enabled the emergence of small-footprint low-cost silicon waveguides for FWM applications, capable of being dispersion engineered to maximize performance [6]. Since the effective bandwidth of the nonlinear interaction is largely determined by the phase-matching conditions over the interaction length, short length dispersion-engineered silicon waveguides can enable ultra-broadband parametric systems, with demonstrated wavelength conversion bandwidths exceeding 800 nm [7]. We have previously demonstrated wavelength conversion of 40-Gb/s data across 47.7 nm [8]. In this work, we demonstrate wavelength conversion of high-speed data in silicon waveguides continuously across 100 nm, validating the capacity of these silicon waveguides for ultra-broadband parametric systems. We wavelength convert 10-Gb/s data over varying probe-idler separations, and experimentally evaluate the performance of this functionality using bit-error-rate (BER) characterization and power penalty performance metrics. We demonstrate error-free (defined as having BERs less than  $10^{-12}$ ) operation of wavelength conversion, and a constant 2-dB power penalty with increasing probe-idler separations from 50 to 100 nm.

## 2. Experiments and results

The device discussed here is a silicon waveguide of 1.1-cm length and a 290-nm × 720-nm cross section, fabricated at the Cornell Nanofabrication Facility using electron-beam lithography followed by reactive-ion etching. Each end of the waveguide has an inverse-taper mode converter for efficient coupling to tapered fibers. The zero-group-velocity-dispersion (ZGVD) wavelength for this waveguide was calculated to be approximately 1577 nm [6].

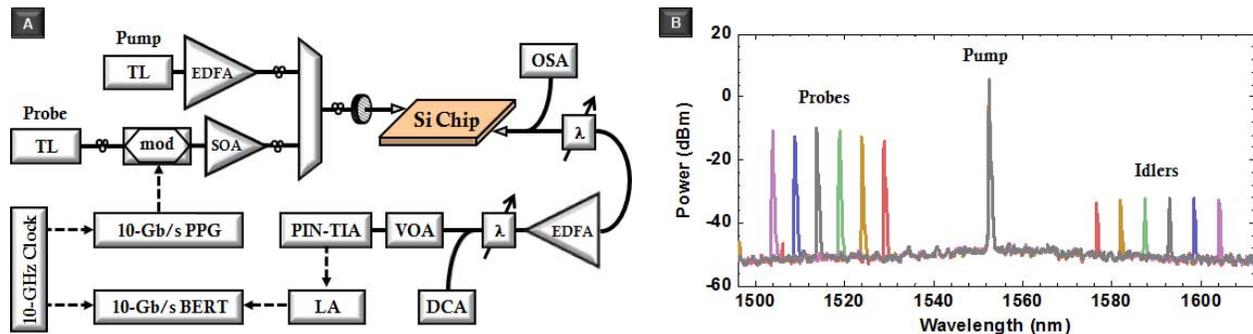


Fig. 1. (a) Diagram of experimental setup used for wavelength conversion. (b) Overlaid spectra of wavelength conversion configurations recorded directly after the chip. Conversion efficiencies remain constant at about -21 dB for all probe-idler separations. Probe wavelengths are set to 1529, 1524, 1519, 1514, 1509, and 1504 nm, corresponding to probe-idler separations of 47, 58, 68, 79, 89, and 100 nm, respectively.

The experimental setup used to evaluate the wavelength conversion (Fig. 1a) includes a continuous-wave (CW) probe produced by a tunable laser (TL) modulated with a 10-Gb/s  $2^{15}-1$  pseudo-random bit sequence (PRBS) pattern from a pulsed-pattern generator (PPG). A CW 1552.5-nm pump is created by amplifying the output of a TL using an erbium-doped fiber amplifier (EDFA). The modulated probe signal is amplified using a semiconductor optical amplifier (SOA) and combined with the pump. The probe and pump are both set to TE polarization and injected into the device. Following the device, a portion of the power is examined on an optical spectrum analyzer (OSA). The converted data signal is recovered using filtering ( $\lambda$ ) and amplification stages. It is then inspected using a digital communications analyzer (DCA), received using a photodetector (PIN-TIA) followed by a limiting amplifier (LA), and examined on a BER tester (BERT). A variable optical attenuator (VOA) is used to vary the optical power incident on the receiver. We perform the experiments with probe-idler detuning ranges spanning 47 to 100 nm. Open eye diagrams are observed (Fig. 2a) for the converted data signal. Moreover, error-free operation is observed for all configurations, BER curves are experimentally obtained, and the resulting power penalties are measured to be  $2 \pm 0.35$  dB (Fig. 2b). Back-to-back eye diagrams and BER curves are recorded directly after of the modulator.

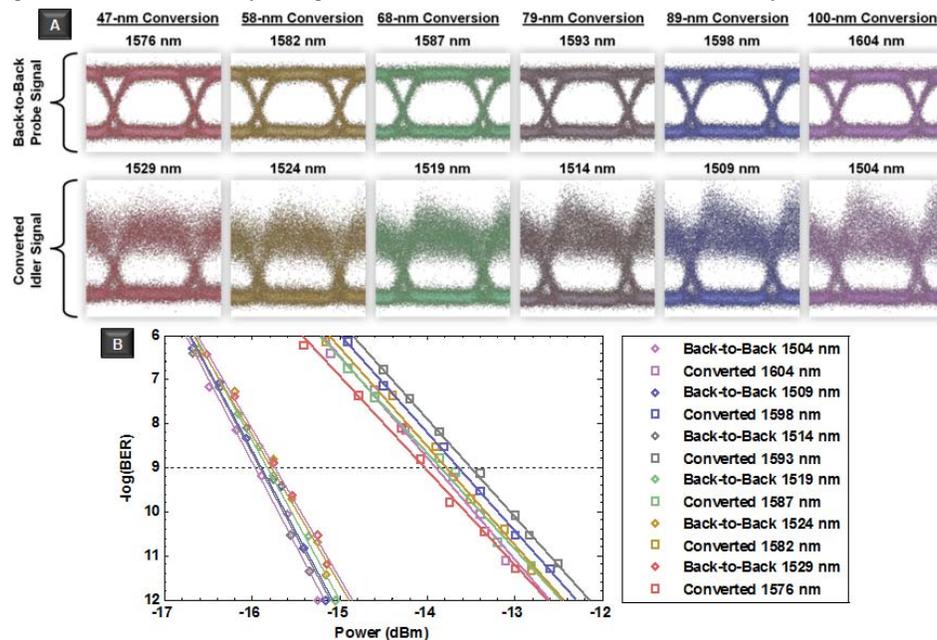


Fig. 2. (a) 10-Gb/s eye diagrams of back-to-back signals above corresponding wavelength-converted signals. Open eye diagrams are observed for all probe-idler separations. (b) 10-Gb/s BER curves of all wavelength-converted and back-to-back signals with constant 2-dB power penalties.

### 3. Conclusion

We have demonstrated a record 100-nm continuous wavelength conversion of 10-Gb/s data using FWM in silicon waveguides. We observed no additional signal degradation from varying probe-idler separations from 50 to 100 nm. The results affirm the utilizable continuous conversion bandwidths spanning the full S-, C-, and L-bands of the ITU grid, potentially enabling full-scale ultrahigh-bandwidth optically-transparent and energy-efficient systems in wavelength-routed networks, developed in the fully-integrated CMOS-compatible platform.

### 4. References

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